

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
1	BRS	L1	29	((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/09 17:38	
2	BRS	L2	2	L1 and (independent\$3 near4 correct\$5) with (multi near2 deflect\$5)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/09 17:36	
3	BRS	L3	0	(250/491.1,492.2,492.22,492.24,397,398)/cc ls.	USPA T; US-P GPUB	2004/11/09 17:30	
4	BRS	L4	3782	(250/491.1,492.2,492.22,492.24,397,398).cc ls.	USPA T; US-P GPUB	2004/11/09 17:30	
5	BRS	L5	1433	430/296.ccls.	USPA T; US-P GPUB	2004/11/09 17:30	
6	BRS	L6	5048	L4 or L5	USPA T; US-P GPUB	2004/11/09 17:34	
7	BRS	L7	8334	L6 or (250/396R,396ML,492.3,492.1,492.3).ccls.	USPA T; US-P GPUB	2004/11/09 17:34	
8	BRS	L8	14	L7 and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/09 17:41	

	Error Definition	Er ro rs
1		0
2		0
3		0
4		0
5		0
6		0
7		0
8		0

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
9	BRS	L9	29	L1 not "L29"	USPAT; US-PGPUB ; EPO; JPO; DERWENT; IBM-TDB	2004/11/09 17:35	
10	BRS	L10	0	L8 not L1	USPAT; US-PGPUB ; EPO; JPO; DERWENT; IBM-TDB	2004/11/09 17:35	
11	BRS	L11	1	L8 and (independent\$3 near4 correct\$5) with (multi near2 deflect\$5)	USPAT; US-PGPUB ; EPO; JPO; DERWENT; IBM-TDB	2004/11/09 17:41	
12	BRS	L12	1	L8 and (independent\$3 with correct\$5) with (multi near2 deflect\$5)	USPAT; US-PGPUB ; EPO; JPO; DERWENT; IBM-TDB	2004/11/09 17:36	

	Error Definition	Er ro rs
9		0
10		0
11		0
12		0

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
13	BRS	L13	2	L1 and (independent\$3 with correct\$5) with (multi near2 deflect\$5)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/0 9 17:37	
14	BRS	L14	2	L1 and (independent\$3 with correct\$5) with (multi\$4 near3 deflect\$5)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/0 9 17:37	
15	BRS	L15	1	L8 and (independent\$3 with correct\$5) with (multi\$4 near3 deflect\$5).	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/0 9 17:38	
16	BRS	L16	407	((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/0 9 17:38	

	Error Definition	Er ro rs
13		0
14		0
15		0
16		0

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
17	BRS	L17	378	L16 not L1	USPAT; US-PGPUB ; EPO; JPO; DERWENT; IBM-TDB	2004/11/09 17:38	
18	BRS	L18	206	L7 and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)	USPAT; US-PGPUB ; EPO; JPO; DERWENT; IBM-TDB	2004/11/09 17:39	
19	BRS	L19	192	L18 not L8	USPAT; US-PGPUB ; EPO; JPO; DERWENT; IBM-TDB	2004/11/09 17:40	
20	BRS	L20	378	L17 or L19	USPAT; US-PGPUB ; EPO; JPO; DERWENT; IBM-TDB	2004/11/09 17:40	

	Error Definition	Er ro rs
17		0
18		0
19		0
20		0

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
21	BRS	L21	1	L18 and (independent\$3 near4 correct\$5) with (multi near2 deflect\$5)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/0 9 17:42	
22	BRS	L22	2	L16 and (independent\$3 near4 correct\$5) with (multi near2 deflect\$5)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/0 9 17:42	
23	BRS	L23	13	L16 and (multi\$4 near2 deflect\$5)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/0 9 17:42	
24	BRS	L24	12	L18 and (multi\$4 near2 deflect\$5)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/0 9 17:44	

	Error Definition	Er ro rs
21		0
22		0
23		0
24		0

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
25	BRS	L25	11	L20 and (multi\$4 near2. deflect\$5)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/0 9 17:44	
26	BRS	L26	11	L23 and independent\$3	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/0 9 17:45	
27	BRS	L27	10	L24 and independent\$3	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/0 9 17:45	
28	BRS	L28	9	L25 and independent\$3	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB	2004/11/0 9 17:45	

	Error Definition	Er ro rs
25		0
26		0
27		0
28		0

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
29	BRS	L29	11	L26 or L27 or L28	USPAT; US-P GPUB ; EPO; JPO; DERW ENT; IBM- TDB	2004/11/09 17:45	

	Error Definition	Er ro rs
29		0

L Number	Hits	Search Text	DB	Time stamp
1	29	((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:38
2	2	((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error) and (independent\$3 near4 correct\$5) with (multi near2 deflect\$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:36
3	0	(250/491.1,492.2,492.22,492.24,397,398)/ccl	USPAT; US-PGPUB	2004/11/09 17:30
4	3782	(250/491.1,492.2,492.22,492.24,397,398).ccl	USPAT; US-PGPUB	2004/11/09 17:30
5	1433	430/296.ccls.	USPAT; US-PGPUB	2004/11/09 17:30
6	5048	((250/491.1,492.2,492.22,492.24,397,398).ccl or 430/296.ccls.	USPAT; US-PGPUB	2004/11/09 17:34
7	8334	((250/491.1,492.2,492.22,492.24,397,398).ccl or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.	USPAT; US-PGPUB	2004/11/09 17:34
8	14	((250/491.1,492.2,492.22,492.24,397,398).ccl or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:41
9	29	((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error) not "L29"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:35
10	0	((250/491.1,492.2,492.22,492.24,397,398) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error) not ((electron adj1 beam) near3 (exposure adj2 (method or apparatus)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:35
11	1	and ((250/491.1,492.2,492.22,492.24,397,398) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error) and (independent\$3 near4 correct\$5) with (multi near2 deflect\$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:41
12	1	((250/491.1,492.2,492.22,492.24,397,398) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error) and (independent\$3 with correct\$5) with (multi near2 deflect\$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:36
13	2	((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error) and (independent\$3 with correct\$5) with (multi near2 deflect\$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:37
14	2	((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error) and (independent\$3 with correct\$5) with (multi\$4 near3 deflect\$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:37

15	1	(((((250/491.1,492.2,492.22,492.24,397,398) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)) and (independent\$3 with correct\$5) with (multi\$1 near2 deflect\$5)) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:38
16	407	(((((250/491.1,492.2,492.22,492.24,397,398) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)) and (independent\$3 with correct\$5) with (multi\$1 near2 deflect\$5)) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:38
17	378	((((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)) not ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)) and (independent\$3 with correct\$5) with (multi\$1 near2 deflect\$5)) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:38
18	206	(((((250/491.1,492.2,492.22,492.24,397,398) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)) and (correct\$5 near4 position\$3)) and (correct\$5 near4 position\$3 near3 error)) and (independent\$3 with correct\$5) with (multi\$1 near2 deflect\$5)) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:39
19	192	(((((250/491.1,492.2,492.22,492.24,397,398) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)) not ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)) and (independent\$3 with correct\$5) with (multi\$1 near2 deflect\$5)) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:40
20	378	(((((250/491.1,492.2,492.22,492.24,397,398) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)) not ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)) and (independent\$3 with correct\$5) with (multi\$1 near2 deflect\$5)) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:40
21	1	(((((250/491.1,492.2,492.22,492.24,397,398) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)) not ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)) and (independent\$3 with correct\$5) with (multi\$1 near2 deflect\$5)) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:42
22	2	(((((250/491.1,492.2,492.22,492.24,397,398) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)) not ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)) and (independent\$3 with correct\$5) with (multi\$1 near2 deflect\$5)) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:42
23	13	(((((250/491.1,492.2,492.22,492.24,397,398) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)) not ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)) and (independent\$3 with correct\$5) with (multi\$1 near2 deflect\$5)) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/11/09 17:42

29	11	((((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)) and (multi\$4 near2 deflect\$5)) and independent\$3) or ((((((250/491.1,492.2,492.22,492.24,397,398).ccls.) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)) and (multi\$4 near2 deflect\$5)) and independent\$3) or ((((((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)) not ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)))) or ((((((250/491.1,492.2,492.22,492.24,397,398).ccls.) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3)) not (((((250/491.1,492.2,492.22,492.24,397,398).ccls.) or 430/296.ccls.) or (250/396R,396ML,492.3,492.1,492.3).ccls.) and ((electron adj1 beam) near3 (exposure adj2 (method or apparatus))) and (correct\$5 near4 position\$3 near3 error)))) and (multi\$4 near2 deflect\$5)) and independent\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB ((250/491.1,492.2,492.22,492.24,397,398).ccls.)	2004/11/09 17:45
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